

Periodically Gated Bilayer Graphene as an Electronic Metamaterial

Xianqing Lin^{1,2} and David Tománek^{1,*}

¹*Physics and Astronomy Department, Michigan State University, East Lansing, Michigan 48824, USA*

²*College of Science, Zhejiang University of Technology, Hangzhou 310023, China*



(Received 28 October 2019; accepted 2 January 2020; published 13 March 2020)

This paper is a contribution to the joint Physical Review Applied and Physical Review Materials collection titled
Two-Dimensional Materials and Devices.

We study ballistic transport in periodically gated bilayer graphene as a candidate for a two-dimensional electronic metamaterial. Our calculations use the equilibrium Green's-function formalism and take into account quantum corrections to charge density changes induced by a periodically modulated top-gate voltage. Our results reveal an intriguing interferencelike pattern, similar to that of a Fabry-Perot interferometer, in the resistance map as a function of the voltage V_{BG} applied to the extended bottom gate and V_{TG} applied to the periodic top gate.

DOI: [10.1103/PhysRevApplied.13.034034](https://doi.org/10.1103/PhysRevApplied.13.034034)

I. INTRODUCTION

Photonic metamaterials are artificial structures used to control propagation of light waves [1]. Their frequency-dependent electromagnetic response in terms of transmission, reflection, and refraction can be tailored using designer periodic arrays of structural elements spaced closer than the wavelength of light [2–14]. Just as a photonic metamaterial is capable of manipulating a coherent electromagnetic wave [1], so an electronic metamaterial should be able to manipulate a coherent wave of electrons [15,16]. Just as the propagation of light can be controlled by periodically modulating the index of refraction and the speed of light c in a three-dimensional (3D) crystal [7,9], so the propagation of electrons can be controlled by modulating the electrostatic potential and Fermi velocity v_F in a two-dimensional (2D) graphene bilayer [17–20]. The same qualitative behavior should be expected of coherent waves of electrons and photons, with the main difference that the electrostatic potential is much easier to modulate than the index of refraction [17]. Then, phenomena including scattering, interference, diffraction of light, and uncommon behavior of photons in an optical metamaterial [2–5,7,9–11] should occur on a wider and more flexible range when manipulating electrons in an electronic metamaterial. In particular, a periodically gated 2D semiconductor may display the same transmission behavior for electrons [21] as a distributed Bragg reflector (DBR) does for photons [22,23].

To explore the possibility of constructing a 2D electronic metamaterial, we study theoretically the

propagation of electrons in periodically gated bilayer graphene. Our calculations use the equilibrium Green's-function formalism to describe ballistic transport in bilayer graphene (BLG) and consider quantum corrections to charge-density changes induced by a periodic modulation of the top-gate (TG) voltage. Our results reveal an intriguing interferencelike pattern, similar to that of a Fabry-Perot interferometer, in the resistance map as a function of the voltages applied to the extended bottom gate (BG), V_{BG} , and to the periodic top gate, V_{TG} .

Due to its atomic-scale perfection and unique electronic structure, monolayer graphene (MLG) has emerged as an ideal 2D material for the study of charge transport [24]. Much attention has been paid to ballistic transport of electrons and suppression of backscattering by Klein tunneling in MLG, including the effect of p - n junctions, local and periodic gating, interaction with the substrate, and the presence of a magnetic field [25–37]. The band structure of MLG at the six Fermi points in the Brillouin zone is characterized by Dirac cones, which formally describe massless particles with constant v_F independent of doping.

Our study is devoted to periodically gated BLG which, just like MLG, is a semimetal. Unlike in MLG, scattering is not suppressed by Klein tunneling due to the lowered symmetry of BLG. In the absence of Klein tunneling, the resistance of BLG can be tuned to be very high. The band structure of BLG is qualitatively different from that of MLG, as it is characterized by parabolas and not Dirac cones near E_F . Consequently, v_F and thus the wavelength of electrons can be modulated by local doping caused by changing the electrostatic potential. Thus, the BLG system appears to be a better candidate for electron optics than MLG, which we also discuss for the sake of reference. The

*tomanek@msu.edu

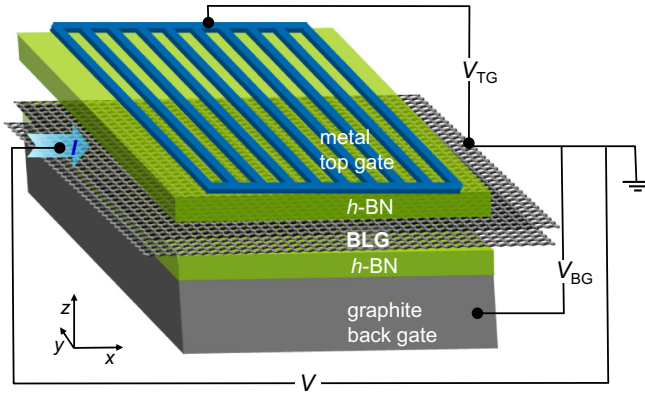


FIG. 1. A schematic view of a periodically gated bilayer-graphene (BLG) device with a top gate formed by a 2D nanowire array and a bottom gate extending across the entire device.

possibility of constructing the electronic counterpart of an optical DBR has not been explored so far.

II. STRUCTURE AND FUNCTIONALITY OF PERIODICALLY GATED BLG

The schematic of a recently fabricated device [38], consisting of periodically gated BLG sandwiched between inert h -BN layers, is presented in Fig. 1. The BLG channel is contacted by metal leads at the source and the drain ends and is separated by an h -BN layer $h_B = 10$ nm thick from the bottom electrode and by an h -BN layer $h_T = 20$ nm thick from the top electrode. The top electrode consists of a periodic array of parallel wires, $W = 25$ nm wide, separated by $L = 120$ nm. The bottom-gate voltage V_{BG} regulates the doping level of the channel, whereas the top-gate voltage V_{TG} modulates the electrostatic potential along the channel. The device performance is characterized by the resistance R between the source and the drain.

To provide an adequate description of the gated BLG device under operating conditions, we distinguish its components and their function in the schematic cross section provided in Fig. 2(a). Only the central region of the device, labeled “I,” lies between the nonuniform top gate of length L_{TG} , formed of a metal wire array, and the bottom gate of length $L_{BG} > L_{TG}$, formed of a graphite slab. This is the region of interest for the electron optics to be discussed below.

Even though region II, which lies between region I and the contacts, may be of lesser interest, it still needs to be addressed in the transport study. This region is above the BG and thus affected by V_{BG} , but outside the range of the TG and thus unaffected by V_{TG} . Key to the interpretation of the resistance in region II is the interface between the BLG and h -BN layers above and below the channel. There is only negligible electronic interaction between the graphene layers and the surrounding h -BN due to its

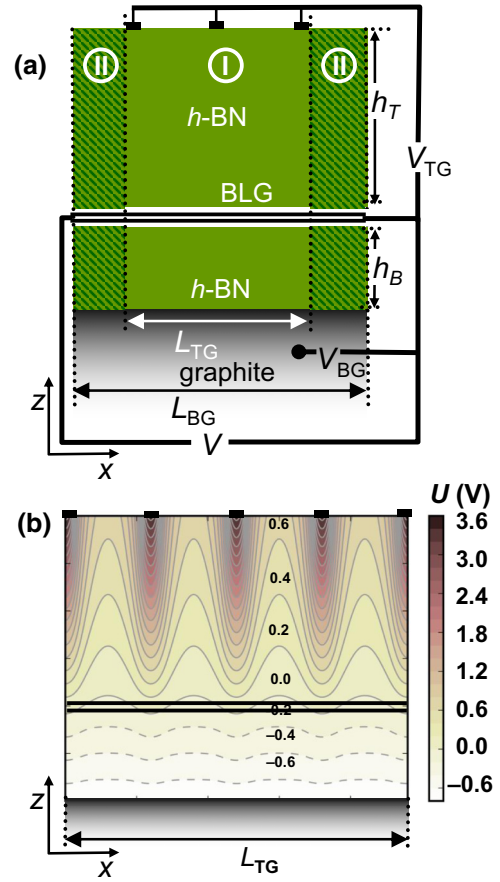


FIG. 2. The relevant regions and the electrostatic potential in a periodically gated BLG device. (a) A schematic side view of the device with BLG in the channel. The BLG is at ground potential and is separated from the top gate by an h_T -thick h -BN sheet and from the bottom gate by an h_B -thick protective h -BN sheet. We distinguish the central region I between the top and bottom gates from region II outside the top gate, but above the bottom gate. (b) The electrostatic potential $U(x, z)$ in the central region I of the device, calculated for $V_{BG} = -0.76$ V and $V_{TG} = 3.48$ V.

5.97-eV-wide band gap [39]. Even if the BLG was perfectly aligned with the h -BN, the 1.8% lattice mismatch would give rise to a Moiré superlattice [32,33]. Minor lattice relaxation in the BLG caused by the graphene - h -BN interaction would then modulate periodically the potential in the graphitic channel, giving rise to second-generation Dirac points [32,33,40–42]. In perfectly aligned BLG/ h -BN superlattices, we expect the electronic density of states (DOS) to vanish at E_F as a consequence of first-generation Dirac points at the charge-neutrality level and at $\Delta E \ll 1$ eV below and above E_F as a consequence of newly formed second-generation Dirac points. For $V_{BG} = 0$, E_F is located at first-generation Dirac points, resulting in high resistance that is independent of V_{TG} and is represented by a line in the $R(V_{TG}, V_{BG})$ resistance map. Applying a bottom-gate voltage V_{BG} induces a nonzero charge density $\sigma_{BLG} = \epsilon V_{BG}/h_B$ in the channel, where ϵ is the dielectric

constant and h_B is the thickness of the lower h -BN layer, as defined in Fig. 2(a). We find that the charge density needed to reach the secondary Dirac points may be induced by $V_{BG} = -1.5$ V when using $\epsilon \approx 7.0\epsilon_0$ [43] and $h_B = 10$ nm in the BLG device. The large resistance at this value of V_{BG} is again independent of V_{TG} , giving rise to a second parallel line in the $R(V_{TG}, V_{BG})$ resistance. For voltages other than $V_{BG} = 0$ V and -1.5 V, the resistance map reflects only the behavior in region I.

III. RESULTS

A. Transport in periodically gated BLG at $T = 0$

To determine the resistance pattern associated with the central region I of interest, we first calculate the electronic structure of BLG and the electrostatic potential U within the plane of the channel as a function of V_{TG} and V_{BG} . For a given $V_{BG} - V_{TG}$ combination, the propagation of ballistic electrons and the net resistance of the gated BLG device are evaluated using the equilibrium Green's-function formalism.

As indicated in Figs. 1 and 2(a), we denote the transport direction x and the direction of the TG wires by y . The width W_{TG} and length L_{TG} of the periodically gated region is much larger than any other dimensions in the device and may be considered infinite. Due to this large size, atomistic calculation of the entire structure is out of the question and would only complicate the interpretation of the transport results in the periodically gated BLG. In the cryogenic regime with a very small applied source-bias voltage, transport in the BLG channel can be considered to be ballistic and attributed to propagation of low-energy charge carriers in a periodically modulated potential $U(x)$.

The low-energy Hamiltonian of a free-standing, ungated BLG can be written as [44]

$$H_{BLG}(k_x, k_y) = \begin{pmatrix} 0 & v_F \mathbf{p}^\dagger & 0 & 0 \\ v_F \mathbf{p} & 0 & \gamma_1 & 0 \\ 0 & \gamma_1 & 0 & v_F \mathbf{p}^\dagger \\ 0 & 0 & v_F \mathbf{p} & 0 \end{pmatrix}. \quad (1)$$

Here, we use $\mathbf{p} = \hbar(k_x + ik_y)$ with (k_x, k_y) to describe the carrier momentum with respect to the Fermi momentum at the Fermi point in the corner of the hexagonal Brillouin zone. The tight-binding parameters describing these systems are [45] the intralayer nearest-neighbor $pp\pi$ hopping integral $\gamma_0 = -2.66$ eV and the interlayer nearest-neighbor $pp\sigma$ hopping integral $\gamma_1 = 0.27$ eV. This yields $\hbar v_F = 3/2(-\gamma_0)d$, where $d = 1.42$ Å is the intralayer nearest-neighbor distance. Only the diagonal matrix elements will be affected by the modulation of the potential in the field of the periodic top gate, since the top-gate period L is much larger than the interatomic spacing.

The two low-energy bands of H_{BLG} are

$$E_{\pm}(k) = \pm \frac{1}{2} \left(-\gamma_1 + \sqrt{4\hbar^2 v_F^2 k^2 + \gamma_1^2} \right), \quad (2)$$

where $k = \sqrt{k_x^2 + k_y^2}$ is close to the Fermi momentum k_F . $E_+(k)$ describes the dispersion in the conduction band and $E_-(k)$ that in the valence band.

In BLG gated by a periodic top and a uniform bottom gate, the net electron-number density $n(x)$ varies periodically along the transport direction and is constant in the y direction. In BLG with isotropic band dispersion at E_F , we find

$$n(x) = \text{sign}(n) k_F^2(x)/\pi, \quad (3)$$

where $k_F(x)$ is the Fermi wave vector at position x . There is particle-hole symmetry with positive n for electron and negative n for hole doping.

The dependence of the charge density n and the Fermi momentum k_F on x is in response to the periodic electrostatic potential $U(x)$ in the plane of the BLG. With the contact lead at the drain end at ground potential, which sets $E_F = 0$ within the BLG, this potential is given by

$$(-e)U(x) = -E_{\eta}(k_F(x)), \quad (4)$$

where e is the absolute value of the electron charge. The subscript η in the expression for E_{η} in Eq. (2) is either $+$ in the case of electron doping or $-$ in the case of hole doping. The sign of $U(x)$ is the same as that of $E_{\eta}(k_F(x))$ and $n(x)$.

In principle, $U(x)$ could be obtained for any gate geometry by solving the Poisson equation [31]. To avoid this calculation for every combination of V_{BG} and V_{TG} , we use an alternative approach. We note that in BLG exposed to the periodic electrostatic potential $U(x)$ caused by the TG voltage V_{TG} and the BG voltage V_{BG} , $n(x)$ can be expressed by

$$n(x) = -\frac{1}{e} \{ C_T(x)[U(x) - V_{TG}] + C_B(x)[U(x) - V_{BG}] \}. \quad (5)$$

Here, the doping charge density $n(x)$ has been related to changes in the potential by the position-dependent partial capacitances [31] $C_T(x)$ of the top gate and C_B of the bottom gate. The above expression can be rewritten as

$$\begin{aligned} n(x) &= \frac{1}{e} [C_T(x)V_{TG} + C_B V_{BG}] \\ &\quad + \frac{1}{e} [C_T(x)V_0 + C_B V_0] \frac{U(x)}{V_0} \\ &= n_c(V_{BG}, V_{TG}, x) + n_c(V_0, V_0, x) \frac{U(x)}{V_0}, \end{aligned} \quad (6)$$

which defines a new quantity, namely the classical net electron-number density n_c . This quantity depends on the

position x within the BLG, considered to be a classical metal, the gate geometry, and the gate voltages V_{TG} and V_{BG} . n_c is nominally defined by $n_c(V_{\text{BG}}, V_{\text{TG}}, x) = (1/e)[C_T(x)V_{\text{TG}} + C_B V_{\text{BG}}]$ and can be calculated in the BLG plane using classical electrostatics for the specific gate geometry. For a given charge density σ_T distributed uniformly across the top-gate wires, which are separated from the grounded BLG by a dielectric of thickness h_T and dielectric constant ϵ , we can numerically determine $n_c(x)$ and the electric field in the entire region using the image-charge technique, which also guarantees a constant zero potential in the BLG layer. Integrating the electric field between the TG and the BLG yields the corresponding value of V_{TG} and the same approach can be used for the bottom gate. We note that V_{TG} is proportional to σ_T and V_{BG} is proportional to σ_B , providing quantitative values for $C_T(x)$ and C_B . V_0 is a nominal voltage value taken to be $V_0 = 1$ V.

Substituting Eqs. (4) and (6) into Eq. (3), we obtain an equation for k_F as a function of x :

$$\begin{aligned} n_c(V_{\text{BG}}, V_{\text{TG}}, x) + n_c(V_0, V_0, x) \frac{E_\eta(k_F(x))}{eV_0} \\ = \text{sign}(n_c) \frac{k_F^2(x)}{\pi}, \end{aligned} \quad (7)$$

where $\eta = \text{sign}[n_c(V_{\text{BG}}, V_{\text{TG}}, x)]$.

We note that considering the grounded BLG channel as a classical metal, nonzero V_{TG} and V_{BG} can induce periodic variation in the classical density $n_c(x) = n_c(V_{\text{BG}}, V_{\text{TG}}, x)$ while keeping the electrostatic potential $U(x, z = 0)$ constant within the BLG. The fact that BLG is not a classical metal but a semimetal with a vanishing DOS at E_F necessitates further consideration. Unlike in a classical metal with a large DOS at E_F , periodic variations of $n_c(x)$ in BLG with a small DOS at E_F will cause a nominal periodic modulation of E_F . To keep E_F constant, the classical carrier density n_c within the BLG will be modified by what we call a quantum correction $n(x) - n_c(x)$. In this better description, the periodic electrostatic potential $U(x, z = 0)$ in the semimetallic BLG is no longer constant and will play an important role. Then, $U(x, z)$ for a given z between the BG and the BLG will also no longer be constant. In the region between the TG and BLG, quantum corrections dampen the oscillations in $U(x, z)$ at constant z . The electrostatic potential $U(x, z)$ associated with the quantum-corrected carrier density $n(x)$ within the BLG, caused by $V_{\text{TG}} = 3.48$ V and $V_{\text{BG}} = -0.76$ V, is shown in Fig. 2(b) for the central region I and z between the TG and the bottom gate.

Being able to determine the electrostatic potential $U(x)$ and the position-dependent Fermi momentum $k_F(x)$ using Eq. (7), we can express the position-dependent potential energy $\phi(x)$ of low-energy electrons or holes in BLG by

$$\phi(x) = (-e)U(x) = -E_\eta(k_F(x)). \quad (8)$$

For BLG in the periodic potential-energy surface $\phi(x)$, the system becomes a superlattice with the lattice constant L along the x direction, with $L = 120$ nm for the device shown in Fig. 1. The low-energy bands of this superlattice are given by the eigenvalues of

$$\tilde{H}_{\text{BLG}} = \begin{pmatrix} \phi(x) & v_F \mathbf{p}^\dagger & 0 & 0 \\ v_F \mathbf{p} & \phi(x) & \gamma_1 & 0 \\ 0 & \gamma_1 & \phi(x) & v_F \mathbf{p}^\dagger \\ 0 & 0 & v_F \mathbf{p} & \phi(x) \end{pmatrix}. \quad (9)$$

Here, the wave vector \mathbf{p} with respect to the Fermi momentum, defined in Eq. (1), has become the operator $\mathbf{p} = (-i\partial/\partial x + ik_y)$ due to the x dependence of the diagonal elements. Since $\phi(x)$ varies very slowly and thus can be represented by only a small number of Fourier components, \tilde{H}_{BLG} can be diagonalized using as basis the eigenfunctions of the free-standing $H_{\text{BLG}}(k_x, k_y)$ with the momentum vectors in the superlattice geometry.

The electronic band structure of the gated BLG is presented in Fig. 3(a) for representative values $V_{\text{TG}} = 4.76$ V and $V_{\text{BG}} = -1.34$ V. The data presented in the left panel display $E(k_x, k_y)$ at two values of k_x in the short Brillouin zone of the superlattice. The shaded regions between the bands indicate the range of band dispersion and the white regions indicate local band gaps. We note that BLG becomes charge neutral when all bands below the charge-neutrality level, shown by the green dashed line, become occupied. The band dispersion along k_x , shown for two k_y values in the two right panels, indicates that bands are almost flat and separated by gaps near the zero-energy level. We find that at other values of V_{TG} and V_{BG} , the band structure is qualitatively very similar but shifts periodically with respect to E_F .

The conductance G is known to be quantized in a system with a finite cross section in the ballistic regime [46]. To interpret transport in the device that we investigate, we need to consider its finite width $W_{\text{TG}} = 11.4$ μm . The allowed eigenstates will then be standing waves normal to the transport direction and k_y will be quantized. For each k_y value, every band that crosses the zero-energy level along k_x of the superlattice provides one conduction channel. Each conduction channel contributes a conductance quantum $G_0 = 2e^2/h = (12.9 \text{ k}\Omega)^{-1}$. Then, the total conductance G is obtained by counting the number of k_y values associated with bands dispersing along the k_x direction that cross the zero-energy level. The total number of conduction channels in the real device of width W_{TG} becomes

$$M = \sum_{k_y} f(k_y), \quad (10)$$

where the allowed k_y values are integer multiples of $2\pi/W_{\text{TG}}$ and $f(k_y)$ is the average transmission probability per k_y mode. At $T = 0$ K, an allowed state with given

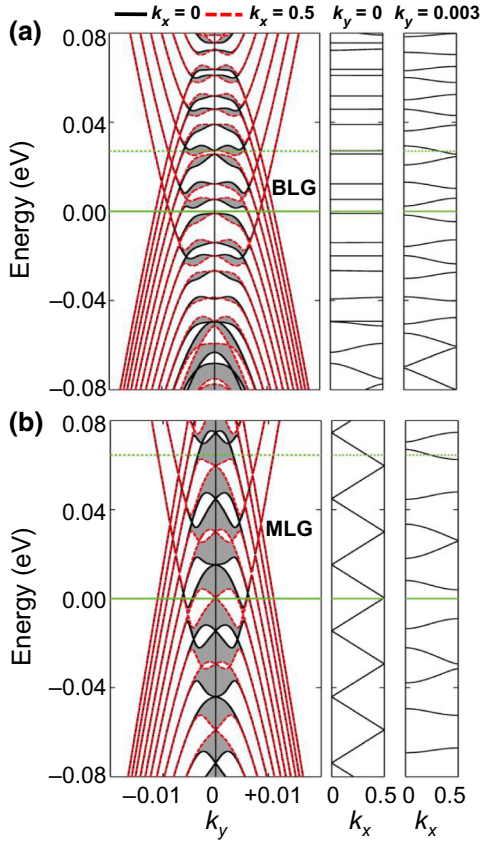


FIG. 3. The electronic band structure of gated (a) BLG and (b) MLG. The presented $E(k)$ results are obtained for BLG with $V_{TG} = 4.76$ V and $V_{BG} = -1.34$ V in (a) and MLG with $V_{TG} = 4.42$ V and $V_{BG} = -1.36$ V in (b). k_x is given in units of $2\pi/L$ and k_y in units of $2\pi/(\sqrt{3}d)$, where $d = 1.42$ Å is the interatomic distance in graphene. In the left panels of (a) and (b), the black solid lines denote bands with $k_x = 0$ and the red dashed lines denote bands with $k_x = 0.5$ at the Brillouin zone boundary. The green solid lines denote the $E = E_F = 0$ energy level and the green dashed lines denote the gate-dependent charge-neutrality level in each system. The two right panels in (a) and (b) show band dispersion along k_x for two values of k_y .

(k_x, k_y) is either occupied or empty. In that case, it will fully contribute to transmission with probability $f(k_y) = 1$ if a band crosses the zero-energy level along k_x for a given k_y value or otherwise not contribute at all, so that $f(k_y) = 0$.

Transport calculations for a ballistic device at a nonzero source-drain voltage V_{sd} are typically performed using the nonequilibrium Green's-function formalism [47]. In the device that we consider, which is driven by a source of very small constant current, V_{sd} is negligibly small. In that case, transport can be calculated using the equilibrium Green's function that describes the electronic structure of the unperturbed system.

The resistance of the central region I is then given by $R = G^{-1} = (MG_0)^{-1}$. To obtain a smooth map of R at $T = 0$ K as a function of V_{TG} and V_{BG} , we convolute the

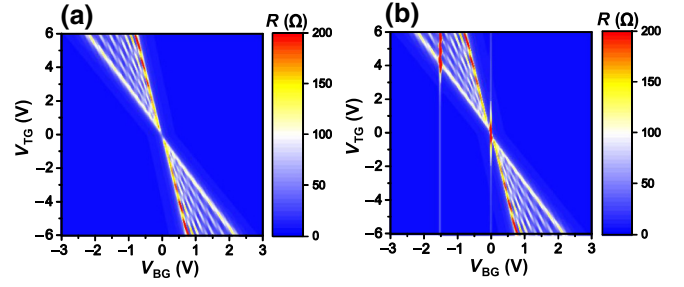


FIG. 4. The calculated resistance map of the BLG device. (a) The calculated source-drain resistance R within the central region I as a function of the top-gate voltage V_{TG} and the bottom-gate voltage V_{BG} . (b) The predicted resistance map of the entire device containing both regions I and II. Two vertical lines at $V_{BG} = 0$ and $V_{BG} \approx -1.5$ V associated with first- and second-generation Dirac points in region II are superimposed onto the resistance gap of region I in (a).

conductance $G(V_{BG}, V_{TG})$ with a Gaussian function at each V_{BG} and obtain

$$\tilde{G}(V_{BG}, V_{TG}) = \frac{1}{\sigma\sqrt{2\pi}} \int G(V_{BG}, V) e^{-(V-V_{TG})^2/2\sigma^2} dV, \quad (11)$$

where 2.355σ is the full width at half maximum of the Gaussian function. The smooth resistance map $\tilde{R}(V_{BG}, V_{TG}) = 1/\tilde{G}(V_{BG}, V_{TG})$ is then obtained and compared with the experimental results.

Figure 4(a) shows the calculated smooth resistance map of the central region I and Fig. 4(b) that of the entire device with $L = 120$ nm and $W = 25$ nm.

Electrons are doped into BLG at positive gate voltages and holes at negative gate voltages. At negative bottom-gate voltages V_{BG} and negative or small positive top-gate voltages V_{TG} , BLG is hole doped everywhere and thus shows low resistance, represented by the uniform dark blue color of the bottom left region of the resistance map in Fig. 4(a). At large positive values of V_{TG} and V_{BG} , on the other hand, BLG is electron doped everywhere and thus also shows low resistance, as indicated by the same dark blue color of the top right region in the resistance map. At given $V_{BG} < 0$ combined with moderate $V_{TG} > 0$ values, and alternatively at given $V_{BG} > 0$ combined with moderate $V_{TG} < 0$ values, regions of hole and electron doping in BLG alternate along the transport direction x . In that case, the sign of $n(x)$ and $\phi(x)$ also alternates along the x direction and the electrons, which are injected at the zero-energy level $E_F = 0$ at the source contact, have to tunnel through a periodic array of potential barriers. Then, constructive or destructive interference may cause significant oscillations in the net resistance, as seen in Fig. 4(a), similar to a Fabry-Perot interferometer.

In order to understand the origin of oscillations of $R(V_{\text{TG}}, V_{\text{BG}})$ in the resistance map, we refer to the calculated band structure of the BLG superlattice in a constant potential, shown in Fig. 3(a). The results shown in the middle panel of Fig. 3(a) indicate that the band dispersion along k_x near $k_y = 0$ of the superlattice is very small. The white regions in the left panel of Fig. 3(a) correspond to band gaps near $k_y = 0$, which are not affected by this small band dispersion along k_x . When the zero-energy level E_F lies in such a local gap, electrons injected at E_F cannot propagate, corresponding to a high resistance. At somewhat larger k_y values such as $|k_y| = 0.003$, the band dispersion along k_x increases, as seen in the right panel of Fig. 3(a). In that case, a momentum (k_x, k_y) may be found at which a band crosses E_F , thus forming a conductance channel and reducing the resistance. As seen in the left panel of Fig. 3(a), the band dispersion along k_x decreases again at still larger values of $|k_y|$, thus lowering the likelihood of transmission and increasing the resistance. As mentioned earlier, this discussion considers charge transport in the special case of a constant potential. Changing the gate voltages changes and modulates the potential along the transport direction. Gradual changes in the potential move the band structure locally up or down in energy with respect to E_F , thus changing the number of bands crossing E_F along x . A transmission channel will then only contribute a conductance quantum if it is open for all values of x . The above reasoning explains the appearance of alternating conductance and resistance maxima associated with changing gate voltages.

B. Effect of temperature on transport in periodically gated BLG

Unlike at $T = 0$ K discussed so far, the allowed (k_x, k_y) states near E_F may be partially occupied by the Fermi-Dirac distribution at $T > 0$. Then, the average transmission probability $f(k_y)$ per k_y mode, introduced in Eq. (10), may take a value in the entire range $0 \leq f \leq 1$ for each band along k_x . Accommodating the band dispersion along k_x , we find that [46]

$$f(k_y) = \sum_m \left(\frac{1}{e^{E_m^{\min}(k_y)/k_B T} + 1} - \frac{1}{e^{E_m^{\max}(k_y)/k_B T} + 1} \right), \quad (12)$$

where we give all energies with respect to $E_F = 0$. We further note a near-linear dispersion of the m th band along k_x , ranging from $E_m^{\min}(k_y)$ to $E_m^{\max}(k_y)$, for a given value of k_y . k_B is the Boltzmann constant.

The effect of temperature on the resistance map, traced back to the temperature dependence of the channel transmission probability in Eq. (12), is shown in Fig. 5. Results for identical gate geometries indicate no net shifts but just thermal smearing of $R(V_{\text{TG}}, V_{\text{BG}})$.

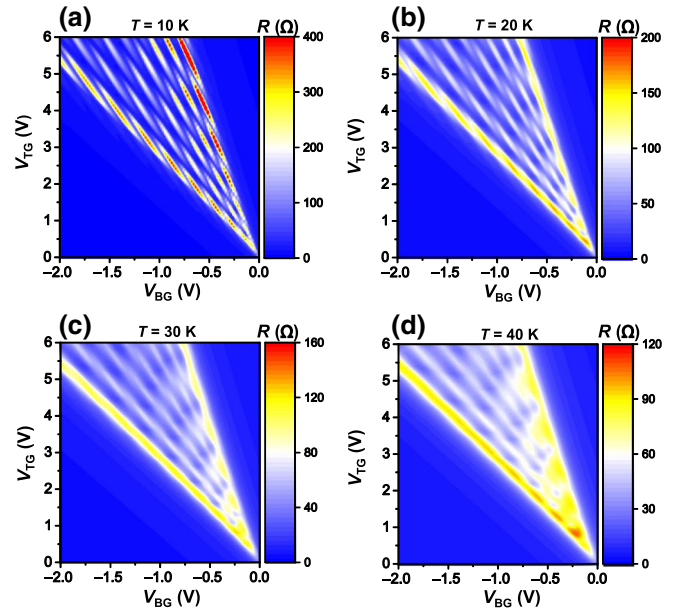


FIG. 5. The calculated resistance maps of the BLG device at temperatures (a) $T = 10$ K, (b) $T = 20$ K, (c) $T = 30$ K, and (d) $T = 40$ K.

C. Effect of geometry on transport in periodically gated BLG

The resistance map $R(V_{\text{TG}}, V_{\text{BG}})$ also depends on the geometry of the BLG device. To inspect this dependence, we present in Fig. 6 the calculated resistance map of BLG devices with different values of the width W of each wire and the interwire distance L within the periodic top gate. As seen in Fig. 6(a), high-resistance lines become continuous in the case in which $L \gg W$. The results in Figs. 6(b)–6(d) indicate that for a fixed L , the series of high-resistance lines tilts and their number decreases with increasing W .

D. Comparison with periodically gated MLG

As a matter of reference, we compare in the following our results for BLG to MLG in the same device geometry, depicted in Fig. 7(a). In consideration of the absence of Klein tunneling in BLG due to the interlayer coupling, we use BLG rather than monolayer graphene (MLG) here as the channel to demonstrate such a resistance map, as analyzed below. The only difference between the MLG and BLG device is the simpler Hamiltonian, which is given in analogy to Eq. (1) by

$$H_{\text{MLG}} = \begin{pmatrix} 0 & v_F \mathbf{p}^\dagger \\ v_F \mathbf{p} & 0 \end{pmatrix} \quad (13)$$

and which leads to the band structure presented in Fig. 3(b).

The MLG-based device that we consider is nearly identical to that shown in Figs. 1 and 2(a) but with BLG

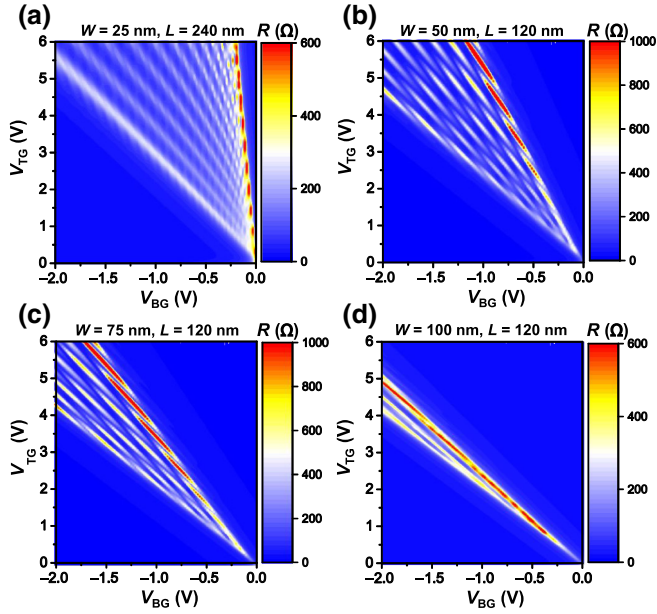


FIG. 6. The calculated resistance maps of BLG devices with different values of the width W of each wire and the interwire distance L within the periodic top gate. Results are presented for (a) $W = 25$ nm, $L = 240$ nm, (b) $W = 50$ nm, $L = 120$ nm, (c) $W = 75$ nm, $L = 120$ nm, and (d) $W = 100$ nm, $L = 120$ nm. The numerical data in the respective panels are convoluted by Gaussians with (a) $\sigma = 0.12$ V, (b) $\sigma = 0.06$ V, (c) $\sigma = 0.04$ V, and (d) $\sigma = 0.04$ V.

replaced by MLG as the channel. The calculated resistance map of the MLG-based device, shown in Fig. 7(b), displays a $R(V_{TG}, V_{BG})$ pattern similar to that of the BLG device. A notable difference between the two is a much lower contrast in the MLG than in the BLG device, with the resistance peak values for MLG being much lower. In addition, compared with MLG, the resistance peaks for BLG are wider and higher and the resistance valleys are also wider and shallower. We also note that in the resistance map without convolution, the MLG device has many more resistance peaks. These peaks in R are well separated but their values are much lower than for the BLG device.

These features in the resistance map of MLG are reflected in its band structure, shown in Fig. 3(b). As seen in the left panel of Fig. 3(b), bands with $k_x = 0$ and with $k_x = 1/2$ always cross E_F at $k_y = 0$ in MLG. Even though there is no gap opening, placing the zero-energy level at this band crossing at $k_y = 0$ gives rise to a resistance maximum. In BLG, on the other hand, the interlayer coupling opens local gaps around $k_y = 0$, resulting in a much higher resistance of the BLG in comparison to the MLG device.

As seen in the middle panel of Fig. 3(b), the MLG bands at $k_y = 0$ are highly dispersive and the energy spectrum is free of gaps. Also, the states at both $(k_x = 0, k_y = 0)$ and $(k_x = 1/2, k_y = 0)$ are doubly degenerate. Thus, $k_y = 0$ states contribute one conduction mode for all values of

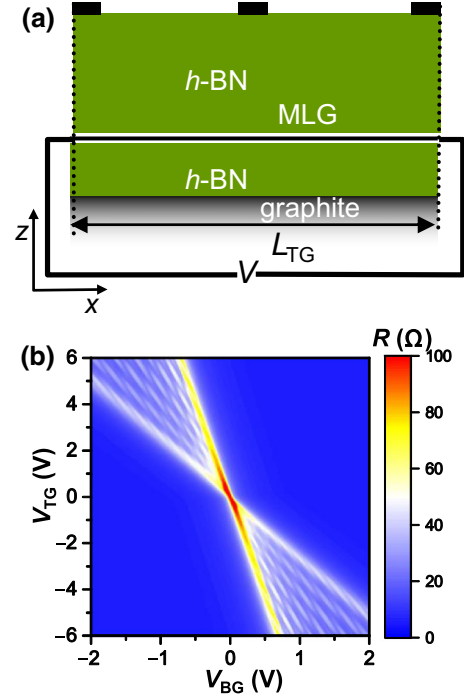


FIG. 7. (a) A schematic cross section and (b) the calculated resistance map of the MLG device. The $R(V_{TG}, V_{BG})$ results are convoluted by a Gaussian with a full width at half maximum of 0.05 V.

V_{TG} and V_{BG} . The absence of scattering in this periodically gated channel is another demonstration of Klein tunneling in MLG.

We note that the double degeneracy of these eigenstates of free-standing MLG is protected in the one-dimensional periodic potential $\phi(x)$ by the symmetry operation

$$O = \begin{pmatrix} 1 & 0 \\ 0 & -1 \end{pmatrix} K, \quad (14)$$

where K is the complex-conjugation operator. This can be explained simply, since the Hamiltonian for MLG,

$$\tilde{H}_{\text{MLG}} = \begin{pmatrix} \phi(x) & v_F \mathbf{p}^\dagger \\ v_F \mathbf{p} & \phi(x) \end{pmatrix}, \quad (15)$$

remains invariant under O , so that the degeneracy of the above-mentioned eigenstates is not broken by any periodic potential $\phi(x)$. We should also note that this symmetry protection only occurs for electrons with $k_y = 0$ corresponding to normal incidence on the wires. There is no symmetry protection for off-normal incidence, so that such electrons may be reflected, giving rise to an interference pattern in the resistance map. Nevertheless, since k_y is near zero for most electrons contributing to transport in the device, most carriers are transmitted and do not contribute to the interference pattern in the resistance map. Since only a minority of electrons undergo reflection and

interference in MLG, the corresponding resistance maxima are less pronounced in the resistance map of MLG.

The situation is different in BLG, where the interlayer hopping integral γ_1 breaks the O symmetry. As seen in the middle panel of Fig. 3(a), BLG bands at $k_y = 0$ show very little dispersion along k_x near E_F due to the interlayer interaction. Since these bands do not cross E_F , the corresponding states do not contribute to conduction, thus lowering the off- or leakage current and increasing the contrast in the resistance map.

As mentioned earlier, BLG is doped by electrons at positive gate voltages and by holes at negative voltages. Even though the magnitude $|v_F|$ of the Fermi velocity does not depend on the sign of the doping carriers, the direction of \mathbf{v}_F in electron-doped BLG is opposite to that of hole-doped BLG. In some respects, this is parallel to the particle-hole symmetry found in BLG and MLG.

IV. SUMMARY AND CONCLUSIONS

In conclusion, we study the propagation of electrons in periodically gated bilayer graphene as a way to construct a 2D electronic metamaterial. We identify an intriguing interferencelike pattern, similar to that of a Fabry-Perot interferometer, in the resistance map in response to doping and potential modulation provided by the extended bottom gate and the periodic top gate. We provide a quantitative explanation for the observations by considering quantum corrections to the position-dependent potential in the channel region and the equilibrium Green's-function formalism that describes ballistic transport in BLG. We find periodically gated BLG to be a suitable candidate for a distributed Bragg reflector for electrons.

V. OUTLOOK

The possibility to artificially modulate the crystal potential is unique to 2D materials and offers previously unexplored ways to expand their usefulness. Particular modulation may be achieved by suitable gate patterning using lithography or using heterostructures in the gate that form by self-assembly or directed assembly on a substrate.

ACKNOWLEDGMENTS

This study has been inspired by Siqi Wang, Mervin Zhao, Changjian Zhang, Sui Yang, Yuan Wang, Kenji Watanabe, Takashi Taniguchi, James Hone, and Xiang Zhang, who kindly discussed their experimental results with us. X.L. and D.T. thank Dan Liu for fruitful discussions. X.L. acknowledges support by the China Scholarship Council and the National Natural Science Foundation of China (Grant No. 11974312). D.T. acknowledges financial support by the National Science Foundation (NSF)/Air Force Office of Scientific Research (AFOSR) Emerging Frontiers in Research and Innovation

(EFRI) 2-Dimensional Advance Materials Research and Engineering (2-DARE) Grant No. EFMA-1433459. Computational resources have been provided by the Michigan State University High Performance Computing Center.

-
- [1] V. G. Veselago, The electrodynamics of substances with simultaneously negative values of ϵ and μ , *Phys. Usp.* **10**, 509 (1968).
 - [2] Hideo Kosaka, Takayuki Kawashima, Akihisa Tomita, Masaya Notomi, Toshiaki Tamamura, Takashi Sato, and Shojiro Kawakami, Superprism phenomena in photonic crystals, *Phys. Rev. B* **58**, R10096 (1998).
 - [3] D. R. Smith, Willie J. Padilla, D. C. Vier, S. C. Nemat-Nasser, and S. Schultz, Composite Medium with Simultaneously Negative Permeability and Permittivity, *Phys. Rev. Lett.* **84**, 4184 (2000).
 - [4] R. A. Shelby, D. R. Smith, and S. Schultz, Experimental verification of a negative index of refraction, *Science* **292**, 77 (2001).
 - [5] J. B. Pendry, D. Schurig, and D. R. Smith, Controlling electromagnetic fields, *Science* **312**, 1780 (2006).
 - [6] Mark I. Stockman, Nanofocusing of Optical Energy in Tapered Plasmonic Waveguides, *Phys. Rev. Lett.* **93**, 137404 (2004).
 - [7] Jie Yao, Zhaowei Liu, Yongmin Liu, Yuan Wang, Cheng Sun, Guy Bartal, Angelica M. Stacy, and Xiang Zhang, Optical negative refraction in bulk metamaterials of nanowires, *Science* **321**, 930 (2008).
 - [8] S. A. Mikhailov and K. Ziegler, New Electromagnetic Mode in Graphene, *Phys. Rev. Lett.* **99**, 016803 (2007).
 - [9] Jason Valentine, Shuang Zhang, Thomas Zentgraf, Erick Ulin-Avila, Dentcho A. Genov, Guy Bartal, and Xiang Zhang, Three-dimensional optical metamaterial with a negative refractive index, *Nature* **455**, 376 (2008).
 - [10] Jason Valentine, Jensen Li, Thomas Zentgraf, Guy Bartal, and Xiang Zhang, An optical cloak made of dielectrics, *Nat. Mater.* **8**, 568 (2009).
 - [11] Xingjie Ni, Zi Jing Wong, Michael Mrejen, Yuan Wang, and Xiang Zhang, An ultrathin invisibility skin cloak for visible light, *Science* **349**, 1310 (2015).
 - [12] Yuanjiang Xiang, Xiaoyu Dai, Jun Guo, Han Zhang, Shuangchun Wen, and Dingyuan Tang, Critical coupling with graphene-based hyperbolic metamaterials, *Sci. Rep.* **4**, 5483 (2014).
 - [13] T. T. Lv, Y. X. Li, H. F. Ma, Z. Zhu, Z. P. Li, C. Y. Guan, J. H. Shi, H. Zhang, and T. J. Cui, Hybrid metamaterial switching for manipulating chirality based on VO₂ phase transition, *Sci. Rep.* **6**, 23186 (2016).
 - [14] Jinhui Shi, Zhongjun Li, David K. Sang, Yuanjiang Xiang, Jianqing Li, Shuang Zhang, and Han Zhang, THz photonics in two dimensional materials and metamaterials: Properties, devices and prospects, *J. Mater. Chem. C* **6**, 1291 (2018).
 - [15] D. Dragoman and M. Dragoman, Optical analogue structures to mesoscopic devices, *Prog. Quantum Electron.* **23**, 131 (1999).
 - [16] D. Dragoman and M. Dragoman, Metamaterials for ballistic electrons, *J. Appl. Phys.* **101**, 104316 (2007).

- [17] Andrea F. Young and Philip Kim, Electronic transport in graphene heterostructures, *Annu. Rev. Condens. Matter Phys.* **2**, 101 (2011).
- [18] Anastasia Varlet, Ming-Hao Liu, Viktor Krueckl, Dominik Bischoff, Pauline Simonet, Kenji Watanabe, Takashi Taniguchi, Klaus Richter, Klaus Ensslin, and Thomas Ihn, Fabry-Pérot Interference in Gapped Bilayer Graphene with Broken Anti-Klein Tunneling, *Phys. Rev. Lett.* **113**, 116601 (2014).
- [19] Renjun Du, Ming-Hao Liu, Jens Mohrmann, Fan Wu, Ralph Krupke, Hilbert von Löhneysen, Klaus Richter, and Romain Danneau, Tuning Anti-Klein to Klein Tunneling in Bilayer Graphene, *Phys. Rev. Lett.* **121**, 127706 (2018).
- [20] Rainer Kraft, Jens Mohrmann, Renjun Du, Pranav Balaji Selvasundaram, Muhammad Irfan, Umut Nefta Kanilmaz, Fan Wu, Detlef Beckmann, Hilbert von Löhneysen, Ralph Krupke, Anton Akhmerov, Igor Gornyi, and Romain Danneau, Tailoring supercurrent confinement in graphene bilayer weak links, *Nat. Commun.* **9**, 1722 (2018).
- [21] R. Tsu and L. Esaki, Tunneling in a finite superlattice, *Appl. Phys. Lett.* **22**, 562 (1973).
- [22] F. K. Reinhardt, R. A. Logan, and C. V. Shank, GaAs-Al_xGa_{1-x}As injection lasers with distributed Bragg reflectors, *Appl. Phys. Lett.* **27**, 45 (1975).
- [23] Won-Tien Tsang and Shyh Wang, GaAs-Ga_{1-x}Al_xAs double-heterostructure injection lasers with distributed Bragg reflectors, *Appl. Phys. Lett.* **28**, 596 (1976).
- [24] K. S. Novoselov, A. K. Geim, S. V. Morozov, D. Jiang, Y. Zhang, S. V. Dubonos, I. V. Grigorieva, and A. A. Firsov, Electric field effect in atomically thin carbon films, *Science* **306**, 666 (2004).
- [25] M. I. Katsnelson, K. S. Novoselov, and A. K. Geim, Chiral tunnelling and the Klein paradox in graphene, *Nat. Phys.* **2**, 620 (2006).
- [26] Andrei V. Shytov, Mark S. Rudner, and Leonid S. Levitov, Klein Backscattering and Fabry-Pérot Interference in Graphene Heterojunctions, *Phys. Rev. Lett.* **101**, 156804 (2008).
- [27] C. W. J. Beenakker, Colloquium: Andreev reflection and Klein tunneling in graphene, *Rev. Mod. Phys.* **80**, 1337 (2008).
- [28] Andrea F. Young and Philip Kim, Quantum interference and Klein tunnelling in graphene heterojunctions, *Nat. Phys.* **5**, 222 (2009).
- [29] M. Ramezani Masir, P. Vasilopoulos, and F. M. Peeters, Fabry-Pérot resonances in graphene microstructures: Influence of a magnetic field, *Phys. Rev. B* **82**, 115417 (2010).
- [30] Sudipta Dubey, Vibhor Singh, Ajay K. Bhat, Pritesh Parikh, Sameer Grover, Rajdeep Sensarma, Vikram Tripathi, K. Sengupta, and Mandar M. Deshmukh, Tunable superlattice in graphene to control the number of Dirac points, *Nano Lett.* **13**, 3990 (2013).
- [31] Ming-Hao Liu, Theory of carrier density in multigated doped graphene sheets with quantum correction, *Phys. Rev. B* **87**, 125427 (2013).
- [32] Matthew Yankowitz, Jiamin Xue, Daniel Cormode, Javier D. Sanchez-Yamagishi, K. Watanabe, T. Taniguchi, Pablo Jarillo-Herrero, Philippe Jacquod, and Brian J. LeRoy, Emergence of superlattice Dirac points in graphene on hexagonal boron nitride, *Nat. Phys.* **8**, 382 (2012).
- [33] L. A. Ponomarenko, R. V. Gorbachev, G. L. Yu, D. C. Elias, R. Jalil, A. A. Patel, A. Mishchenko, A. S. Mayorov, C. R. Woods, J. R. Wallbank, M. Mucha-Kruczynski, B. A. Piot, M. Potemski, I. V. Grigorieva, K. S. Novoselov, F. Guinea, V. I. Fal'ko, and A. K. Geim, Cloning of Dirac fermions in graphene superlattices, *Nature* **497**, 594 (2013).
- [34] Shaowen Chen, Zheng Han, Mirza M. Elahi, K. M. Masum Habib, Lei Wang, Bo Wen, Yuanda Gao, Takashi Taniguchi, Kenji Watanabe, James Hone, Avik W. Ghosh, and Cory R. Dean, Electron optics with *p-n* junctions in ballistic graphene, *Science* **353**, 1522 (2016).
- [35] Martin Drienovsky, Franz-Xaver Schrettenbrunner, Andreas Sandner, Dieter Weiss, Jonathan Eroms, Ming-Hao Liu, Fedor Tkatschenko, and Klaus Richter, Towards superlattices: Lateral bipolar multibarriers in graphene, *Phys. Rev. B* **89**, 115421 (2014).
- [36] M. Drienovsky, A. Sandner, C. Baumgartner, M.-H. Liu, T. Taniguchi, K. Watanabe, K. Richter, D. Weiss, and J. Eroms, Few-layer graphene patterned bottom gates for van der Waals heterostructures (2017), <https://arxiv.org/abs/1703.05631>.
- [37] Martin Drienovsky, Jonas Joachimsmeier, Andreas Sandner, Ming-Hao Liu, Takashi Taniguchi, Kenji Watanabe, Klaus Richter, Dieter Weiss, and Jonathan Eroms, Commensurability Oscillations in One-Dimensional Graphene Superlattices, *Phys. Rev. Lett.* **121**, 026806 (2018).
- [38] A working device has been constructed by Siqi Wang, Mervin Zhao, Changjian Zhang, Sui Yang, Yuan Wang, Kenji Watanabe, Takashi Taniguchi, James Hone, and Xiang Zhang (unpublished).
- [39] Kenji Watanabe, Takashi Taniguchi, and Hisao Kanda, Direct-bandgap properties and evidence for ultraviolet lasing of hexagonal boron nitride single crystal, *Nat. Mater.* **3**, 404 (2004).
- [40] Cory R. Dean, L. Wang, P. Maher, C. Forsythe, Fereshte Ghahari, Y. Gao, Jyoti Katoch, M. Ishigami, P. Moon, M. Koshino, K. Watanabe, K. L. Shepard, J. Hone, and P. Kim, Hofstadter's butterfly and the fractal quantum Hall effect in Moiré superlattices, *Nature* **497**, 598 (2013).
- [41] Jeil Jung, Ashley M. DaSilva, Allan H. MacDonald, and Shaffique Adam, Origin of band gaps in graphene on hexagonal boron nitride, *Nat. Commun.* **6**, 6308 (2015).
- [42] John R. Wallbank, Marcin Mucha-Kruczyński, Xi Chen, and Vladimir I. Fal'ko, Moiré superlattice effects in graphene/boron-nitride van der Waals heterostructures, *Ann. Phys.* **527**, 359 (2015).
- [43] R. Geick, C. H. Perry, and G. Rupprecht, Normal modes in hexagonal boron nitride, *Phys. Rev.* **146**, 543 (1966).
- [44] Edward McCann and Mikito Koshino, The electronic properties of bilayer graphene, *Rep. Prog. Phys.* **76**, 056503 (2013).
- [45] David Tomanek and Steven G. Louie, First-principles calculation of highly asymmetric structure in scanning-tunneling-microscopy images of graphite, *Phys. Rev. B* **37**, 8327 (1988).
- [46] Supriyo Datta, *Electronic Transport in Mesoscopic Systems* (Cambridge University Press, Cambridge, 1995).
- [47] P. S. Damle, A. W. Ghosh, and Supriyo Datta, in *Molecular Nanoelectronics*, edited by Mark A. Reed and Takhee T. Lee (American Scientific Publishers, Valencia, 2003).